Accepted Manuscript

Nanostructured Tin Oxide Films: Physical Synthesis, Characterization, and Gas Sensing Properties

S.M. Ingole, S.T. Navale, Y.H. Navale, D.K. Bandgar, F.J. Stadler, R.S. Mane, N.S. Ramgir, S.K. Gupta, D.K. Aswal, V.B. Patil

| PII: | \$0021-9797(17)30025-5 |
|----------------|--|
| DOI: | http://dx.doi.org/10.1016/j.jcis.2017.01.025 |
| Reference: | YJCIS 21931 |
| To appear in: | Journal of Colloid and Interface Science |
| To appear m. | sournal of Conord and Interface Selence |
| Received Date: | 11 November 2016 |
| Revised Date: | 6 January 2017 |
| Accepted Date: | 9 January 2017 |



Please cite this article as: S.M. Ingole, S.T. Navale, Y.H. Navale, D.K. Bandgar, F.J. Stadler, R.S. Mane, N.S. Ramgir, S.K. Gupta, D.K. Aswal, V.B. Patil, Nanostructured Tin Oxide Films: Physical Synthesis, Characterization, and Gas Sensing Properties, *Journal of Colloid and Interface Science* (2017), doi: http://dx.doi.org/10.1016/j.jcis. 2017.01.025

This is a PDF file of an unedited manuscript that has been accepted for publication. As a service to our customers we are providing this early version of the manuscript. The manuscript will undergo copyediting, typesetting, and review of the resulting proof before it is published in its final form. Please note that during the production process errors may be discovered which could affect the content, and all legal disclaimers that apply to the journal pertain.

ACCEPTED MANUSCRIPT

Nanostructured Tin Oxide Films: Physical Synthesis, Characterization, and Gas Sensing Properties

S. M. Ingole^a, S. T. Navale^b, Y. H. Navale^a, D. K. Bandgar^a, F. J. Stadler^b, R. S. Mane^e, N. S. Ramgir^c, S. K. Gupta^c, D. K. Aswal^d, V.B. Patil^a*

^aFunctional Materials Research Laboratory, School of Physical Sciences, Solapur University, Solapur-413255, (MS) India (*Email. <u>drvbpatil@gmailcom</u>)

^bCollege of Materials Science and Engineering, Shenzhen Key Laboratory of Polymer Science and Technology, Shenzhen University, Shenzhen 518060, P. R. China

^cTechnical Physics Division, Bhabha Atomic Research Centre, Trombay, Mumbai, India. ^dNational Physical Laboratory, New Delhi, India.

^eSchool of Physical Sciences, SRTM University, Nanded, (MS), India.

Abstract

Nanostructured tin oxide (SnO₂) films are synthesized using physical method i.e. thermal evaporation and are further characterized with X-ray diffraction, X-ray photoelectron spectroscopy, scanning electron microscopy, transmission electron microscopy, and atomic force microscopy measurement techniques for confirming its structure and morphology. The chemiresistive properties of SnO₂ films are studied towards different oxidizing and reducing gases where these films have demonstrated considerable selectivity towards oxidizing nitrogen dioxide (NO₂) gas with a maximum response of 403% to 100 ppm @200° C, and fast response and recovery times of 4 s and 210 s, respectively, than other test gases. In addition, SnO₂ films are enabling to detect as low as 1 ppm NO₂ gas concentration @200° C with 23% response enhancement. Chemiresistive performances of SnO₂ films are carried out in the range of 1-100 ppm and reported. Finally, plausible adsorption and desorption reaction mechanism of NO₂ gas molecules with SnO₂ film surface has been thoroughly discussed by means of an impedance spectroscopy analysis.

Keywords: Thermal evaporation; Tin oxide, Structure and morphology; NO₂ sensor; Impedance spectroscopy.

Download English Version:

https://daneshyari.com/en/article/4985124

Download Persian Version:

https://daneshyari.com/article/4985124

Daneshyari.com